Patent Claims

1. A method for cleaning at least one process chamber (7) for coating at least one

substrate (3), in particular made from glass,

characterized in that the at least one process chamber (7) is purged with a

conditioned purge gas (15) prior to a coating operation.

2. The method as claimed in claim 1, in which the moisture content of the purge

gas, before it enters the at least one process chamber (7), is set to a predetermined

moisture level, in particular to a relative moisture content of at most 30%, in particular

at most 25%, preferably at most 10% or even at most 5%.

3. The method as claimed in claim 1 or claim 2, in which the purge gas, before it

enters the at least one process chamber (7), has foreign substances removed from it, in

particular by filtering.

4. The method as claimed in one or more of the preceding claims, in which the

temperature of the purge gas, before it enters the at least one process chamber (7), is

set in at least a predetermined temperature range, preferably to at least a

predetermined temperature value, in particular in a temperature range between 20°C

and 90°C, preferably in a temperature range between 60°C and 80°C.

- Page 29 -

WORKMAN NYDEGGER
A PROFESSIONAL CORPORATION
ATTORNEYS AT LAW
1000 EAGLE GATE TOWER

5. The method as claimed in one or more of the preceding claims, in which the

pressure of the purge gas, before it enters the at least one process chamber (7), is set to

at least a predetermined pressure value, preferably in a pressure range between 0.8 bar

and 1.5 bar.

6. The method as claimed in one or more of the preceding claims, in which the

purge gas used is air, in particular ambient air, and/or an inert gas.

7. The method as claimed in one or more of the preceding claims, in which during

a cleaning operation the conditioned purge gas (15) flows, preferably continuously,

through the at least one process chamber (7), and/or at least one cleaning step is

carried out by flooding the process chamber (7) with conditioned purge gas (15) and

then discharging the purge gas (16).

8. A method, in particular the method as claimed in one or more of the preceding

claims, in which, during a or the cleaning operation, a pressure lock which is arranged

at an entry and/or an exit of at least one process chamber (7) for coating at least one

substrate (3), in particular made from glass, is purged with conditioned purge gas or

the conditioned purge gas (15).

9. The method as claimed in one or more of the preceding claims, in which, for

pressure equalization in the pressure lock, conditioned purge gas (15) flows into the

pressure lock and/or in which the pressure lock, before the at least one substrate (3)

passes into the pressure lock and/or while the at least one substrate (3) is in the

pressure lock, is purged with conditioned purge gas (15).

- Page 30 -

Docket No. 16056.13

WORKMAN NYDEGGER
A PROFESSIONAL CORPORATION
ATTORNEYS AT LAW
1000 EAGLE GATE TOWER
60 EACT SOUTHY TEAMS

10. The method as claimed in one or more of the preceding claims, in which the

purge gas is mixed from various gas streams.

11. The method as claimed in one or more of the preceding claims, in which the

purge gas is passed through a circuit.

12. The method as claimed in claim 11, in which the purge gas (16) which emerges

from the at least one process chamber (7) is conditioned with regard to the moisture

content and/or the loading with foreign substances and/or the temperature and/or the

pressure and/or the gas composition.

13. The method as claimed in one or more of the preceding claims, in which the at

least one substrate (3) is pretreated in a substrate treatment operation which precedes

the coating operation, in particular in a substrate drying operation (1) preceded by a

substrate washing operation (22).

14. The method as claimed in claim 13, in which at least some of a conditioned

drying gas (5) for drying the at least one substrate in the substrate drying operation (1)

and/or at least some of a drying gas (19) which is discharged from the substrate drying

operation (1) is at least partly used as conditioned purge gas (15).

15. The method as claimed in one or more of the preceding claims, in which the at

least one process chamber (7) is at least partially heated, preferably from the outside,

in particular at least part of at least one process chamber wall, before and/or during a

cleaning operation.

WORKMAN NYDEGGER A PROFESSIONAL CORPORATION ATTORNEYS AT LAW 16. The method as claimed in claim 15, in which the at least one process chamber

(7) is heated at least in part to a temperature between 20°C and 60°C, in particular

between 40°C and 60°C, in particular inductively and/or by radiation and/or by heat

conduction.

17. The method as claimed in one or more of the preceding claims, in which at least

one pulse generator device (23), before and/or during a coating operation, transmits at

least one mechanical pulse to a process chamber wall, in particular an outer wall (28),

of the at least one process chamber (7).

18. The method as claimed in claim 17, in which as pulse generator device (23) at

least one hammer and/or at least one compressed-air nozzle and/or at least one

vibration unit and/or at least one ultrasound generator is used.

19. The method as claimed in one or more of claims 17 to 18, in which the

mechanical pulse is triggered automatically as a function of at least one process

variable and/or the strength of the mechanical pulse is set as a function of a degree of

contamination.

20. The method as claimed in one or more of claims 17 to 19, in which at least some

of the purge gas (16) which emerges from the at least one process chamber (7) is used

to generate the mechanical pulse.

- Page 32 -

WORKMAN NYDEGGER A PROFESSIONAL CORPORATION ATTORNEYS AT LAW 21. An apparatus for cleaning at least one process chamber (7) for coating at least

one substrate (3), in particular made from glass, in particular for carrying out the

method as claimed in one or more of the preceding claims, characterized in that at

least one purge device is provided for introducing a conditioned purge gas (15) into

the at least one process chamber (7) and/or for passing a conditioned purge gas (15)

through the at least one process chamber (7) prior to a coating operation.

22. The apparatus as claimed in claim 21, in which the at least one purge device

comprises at least one purge gas feed line and at least one purge gas delivery unit (14,

17), in particular a pump and/or a fan, which are arranged upstream and/or

downstream of the at least one process chamber (7) as seen in a direction of flow.

23. The apparatus as claimed in claim 21 or claim 22, in which at least one

conditioning device (9, 11, 13, 14) is provided for conditioning the purge gas before it

enters the process chamber (7).

WORKMAN NYDEGGER
A PROFESSIONAL CORPORATION
ATTORNEYS ATLAW
1000 EAGLE GATE TOWER

24. The apparatus as claimed in claim 23, in which at least one conditioning device

(11) is provided for the purpose of setting a moisture content of the purge gas, in

particular in the form of an adsorption unit or a cooling unit, preferably an absorption

refrigeration machine, and/or

in which at least one conditioning device (13) is provided for

setting a temperature of the purge gas, in particular in the form of a heating

device, and/or

in which at least one conditioning device (14) is provided for

setting a pressure of the purge gas, in particular in the form of a compressor,

and/or

in which at least one conditioning device (9) is provided for

separating foreign substances out of the purge gas, in particular in the form of a

filter unit.

25. An apparatus, in particular the apparatus as claimed in one or more of claims 21

to 24, in which at least one feed device is provided for introducing conditioned purge

gas or the conditioned purge gas (15) into at least one pressure lock which is arranged

at an entry of a process chamber (7) for coating at least one substrate (3), in particular

made from glass, and/or at an exit of a process chamber for coating at least one

substrate (3), in particular made from glass, and/or for passing conditioned purge gas

or the conditioned purge gas (15) through the at least one pressure lock, and/or in

which at least one discharge device is provided for discharging the purge gas from the

at least one pressure lock.

- Page 34 -

Docket No. 16056.13

WORKMAN NYDEGGER
A PROFESSIONAL CORPORATION
ATTORNEYS AT LAW
1000 EAGLE GATE TOWER

26. The apparatus as claimed in one or more of claims 21 to 25, in which at least

one heating device is provided for the purpose of heating at least part of at least one

process chamber (7) before and/or during a cleaning operation, which is preferably

arranged outside the process chamber (7).

27. The apparatus as claimed in one or more of claims 21 to 26, in which at least

one pulse generator device (23) is provided, which prior to a coating operation imparts

at least one mechanical pulse to a process chamber wall, in particular an outer wall

(28), of the at least one process chamber.

28. The apparatus as claimed in one or more of claims 21 to 27, in which the at least

one pulse generator device (23) comprises at least one hammer and/or at least one

compressed-air nozzle and/or at least one vibration unit and/or at least one ultrasound

generator and/or at least one control unit.

29. The apparatus as claimed in one or more of claims 21 to 28, in which there is at

least one means for determining process variables, in particular for detecting a degree

of contamination in the process chamber.

30. The apparatus as claimed in one or more of claims 21 to 29, in which the at least

one conditioning device (9, 11, 13, 14) is at least one conditioning device (9, 11, 13,

14) of a substrate treatment apparatus connected upstream of the at least one process

chamber, in particular of a substrate drying apparatus (1) with upstream substrate

washing apparatus (22).

- Page 35 -

Docket No. 16056.13

WORKMAN NYDEGGER
A PROFESSIONAL CORPORATION
ATTORNEYS ATLAW
1000 EAGLE GATE TOWER
60 EAST SOUTH TEMPLE
SALT LAKE CITY, UTAH 84111

31. The apparatus as claimed in claim 30, in which there is at least one device for introducing at least some of a drying gas (19) which emerges from the substrate drying apparatus and/or at least some of a drying gas (5) which has been prepared in the at least one conditioning device into the process chamber (7) as at least part of the conditioned purge gas (15).

WORKMAN NYDEGGER
A PROFESSIONAL CORPORATION
ATTORNEYS AT LAW
1000 EAGLE GATE TOWER

32. A method for coating at least one substrate, in particular made from glass, in a

process chamber, in which the process chamber (7), prior to a coating operation, is

cleaned by a method as claimed in one or more of claims 1 to 18 and/or using an

apparatus as claimed in one or more of claims 19 to 28.

33. The method as claimed in claim 32, in which after the cleaning operation the

pressure in the process chamber (7) is reduced with respect to the ambient pressure,

preferably to between 10^{-7} bar and 10^{-3} bar, and then a coating process is initiated, in

particular a coating process from the vapor phase, preferably a PVD or CVD process.

34. An apparatus for coating at least one substrate, in particular made from glass, in

a process chamber (7), in particular for carrying out the method as claimed in claim 29

or claim 30, comprising a separate apparatus for cleaning the process chamber (7)

prior to a coating operation by purging with a conditioned purge gas (15), in particular

an apparatus as claimed in one or more of claims 19 to 28.

C:\Documents and Settings\mfrodsham\My Documents\WORKING\Application.Template.doc